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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT APPLICATION of

Chan-Hyung CHO et al.

Group Art Unit: 2815

Application No. 10/780,851

Examiner: E. Wojchechowicz

Filed: February 19, 2004

For: METHOD OF ENLARGING CONTACT AREA OF A GATE ELECTRODE,
SEMICONDUCTOR DEVICE HAVING A SURFACE-ENLARGED GATE
ELECTRODE, AND METHOD OF MANUFACTURING THE SAME

RESPONSE TO ELECTION/RESTRICTION REQUIREMENT

U.S. Patent and Trademark Office
Customer Service Window, Mail Stop Amendment
Randolph Building
401 Dulany Street
Alexandria VA 22314

Sir:

In response to the Office Action of March 23, 2005, Applicants elect the invention
of Group II, Claims 1-31, drawn to a process. The election is without traverse.

Respectfully submitted,

VOLENTINE FRANCOS & WHITT, PLLC

Adam C. Volentine
Registration No. 33,289

One Freedom Square
11951 Freedom Drive, Suite 1260
Reston VA 21090
Tel. (571) 283-0720
Fax (571) 283-0740

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